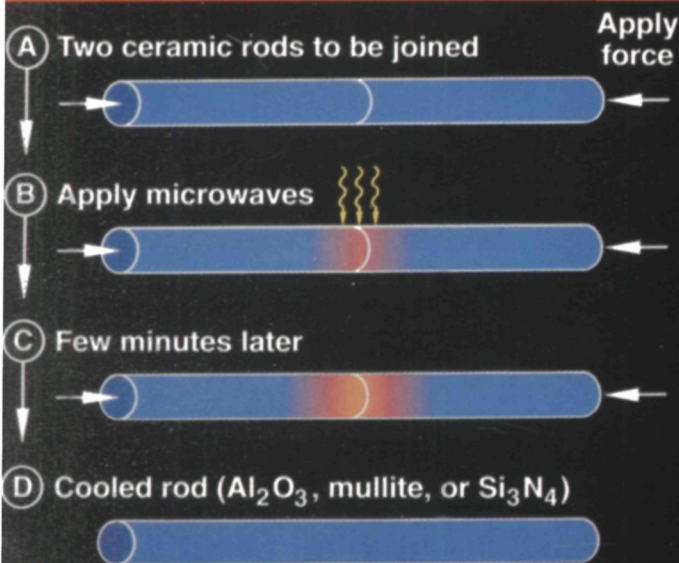


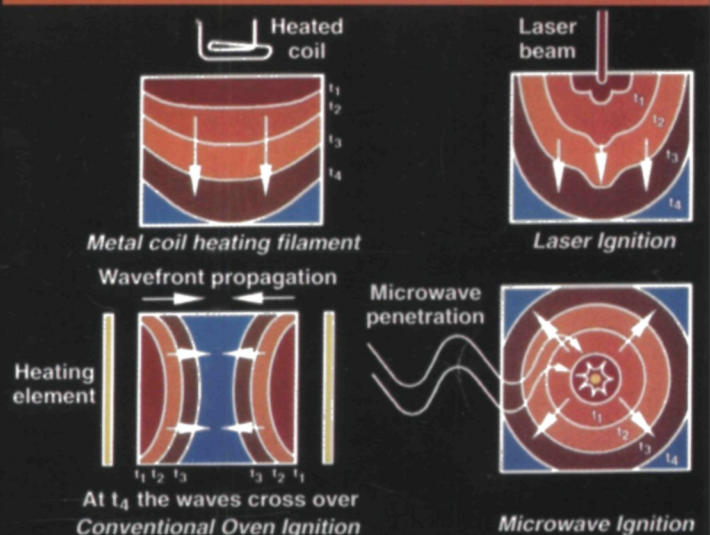


Microwave Processing of Materials

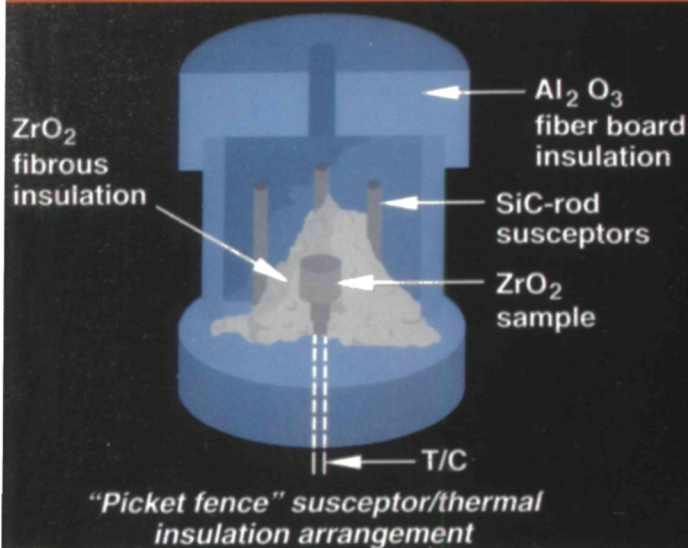
Microwave Joining



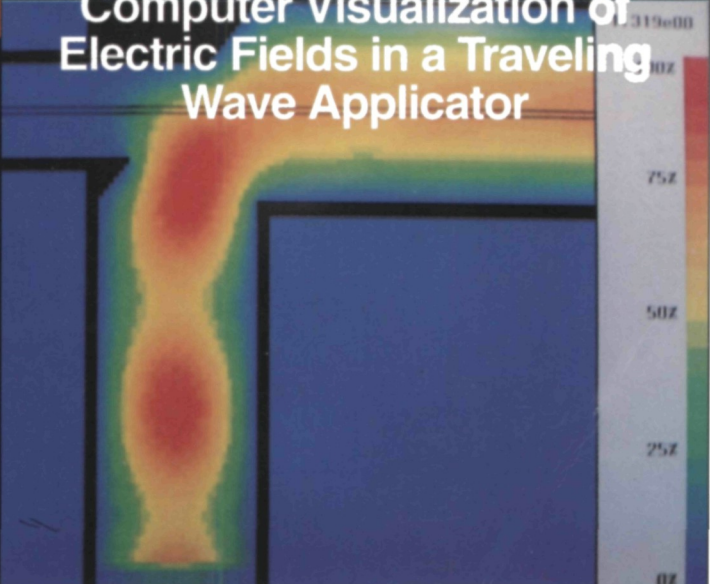
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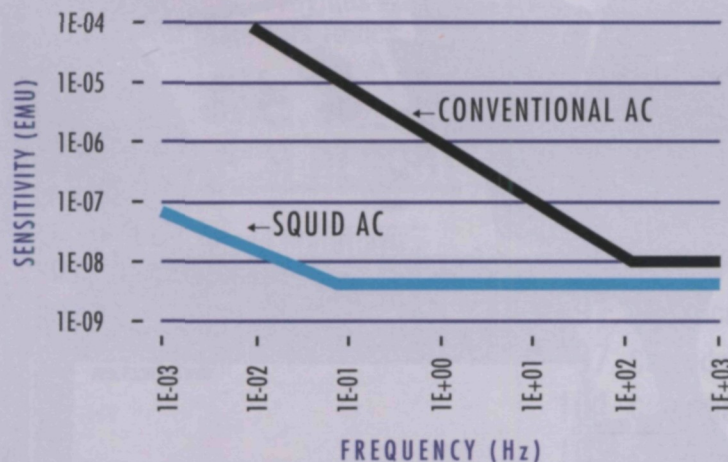
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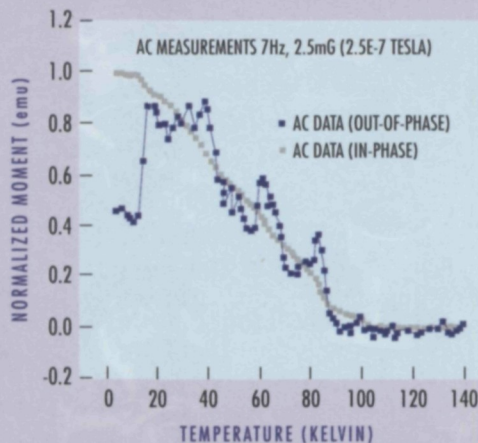


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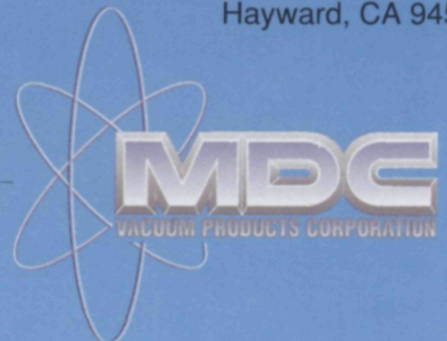
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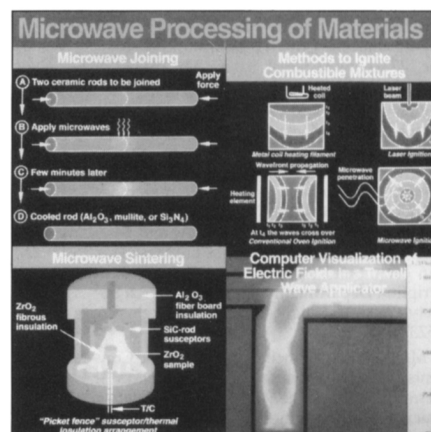
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ON THE COVER: Four aspects of microwave processing are represented: (1) joining of ceramic rods (see the article by R. Silbergliitt et al., p. 47); (2) ignition of combustible mixtures to synthesize materials (see the article by D.E. Clark et al., p. 41); (3) microwave sintering of ZrO₂ using SiC susceptor rods to initiate (hybrid) heating (see M. Janney, C. Calhoun, and H. Kimrey, *J. Am. Ceram. Soc.* **75**, 2, 1992, p. 341); and (4) computer-simulated electric field distribution pattern in a traveling wave applicator (see the article by M. Iskander, p. 30). Photos (1-3) courtesy of United Technologies Research Center, Genigraphics Group; photo (4) courtesy of M. Iskander.

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Guest Editor
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Editorial and Advertising Offices
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